



Docket: P910284

IPW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Yang Chin Cheng

U.S. Serial No: 10/713,762

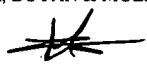
Filed: November 13, 2003

For: METHODS FOR USING A
SILYLATION TECHNIQUE TO
REDUCE CELL PITCH IN
SEMICONDUCTOR DEVICES

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/ Examiner: Pham, Thanhha S.
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/ Group Art: 2813
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Mail Stop Non-Fee Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

I hereby certify that this correspondence is being deposited with the United States Postal Service, First Class mail, postage prepaid, in an envelope addressed to Mail Stop Non-Fee Amendment, Commissioner of Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on September 23, 2005.
STOUT, UXA, BUYAN & MULLINS, LLP


Kenton R. Mullins, Reg. No. 36,331

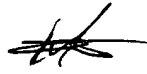
TRANSMITTAL

Sir:

Submitted herewith are:

- (1) Return Receipt Postcard;
- (2) Response to Restriction Requirement;
- (3) Listing of Claims; and
- (4) Deposit Account Authorization: The Commissioner is hereby authorized to charge any needed fees to deposit account 50-1600.

Respectfully submitted,


Kenton R. Mullins
Attorney for Applicant
Reg. No. 36,331

September 23, 2005
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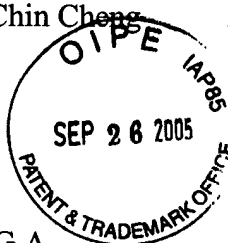
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Examiner: Pham, Thanhha S.

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RESPONSE TO RESTRICTION REQUIREMENT

Sir:

Responsive to the Examiner's Office Action of August 23, 2005, Applicant hereby elects without traverse the invention of Group A-2, directed to the material layer being removed (portions) using the protectant layer as a mask wherein the material layer is selected from a group consisting of a silicon, silicon dioxide, doped silicon dioxide, silicon nitride, poly silicon, aluminum, copper, titanium, titanium nitride, tantalum and tantalum nitride, and Group B-1, directed to a silylation process being performed by a gas phase, corresponding to claims 1, 2, 4, 7-12, 17-19, 21-24, 27 and 28.

Applicant respectfully submits that the application is now in condition for a first action on the merits, and requests that such be done at an early date. Should the Examiner believe that a telephone conference with Applicant's representative would be helpful to advance the prosecution of the application, the Examiner is invited to contact the undersigned with any questions.

Respectfully submitted,

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